

<b>Notice of References Cited</b>	Application/Control No. 09/820,695	Applicant(s)/Patent Under Reexamination LI ET AL.	
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**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
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	C	US-			
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**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	Koshiishi et al., "Effect of Increasing the Upper Frequency on Dual Frequency Capacitive-Coupled-Plasma", Proceedings of Symposium on Dry Process, The Institute of Electrical Engineers of Japan, Nov. 11-13, 1998, pp 229-234.
	V	"After Moore's Law, Why Multiple Processors Matter", MacMusings by Dan Knight, (November 02, 1999) ( <a href="http://www.lowendmac.com/musings/moore.shtml">http://www.lowendmac.com/musings/moore.shtml</a> )
	W	"Intel, IBM put chip development in fast lane", by Michael Kanellios (Dec. 10, 2000), ( <a href="http://news.com.com/Intel%2C+IBM+put+chip+development+in+fast+lane/2100-1001_3-249656.html">http://news.com.com/Intel%2C+IBM+put+chip+development+in+fast+lane/2100-1001_3-249656.html</a> )
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